Body Biasing Injection Attacks in Practice

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Agenda

- Body Biasing Injection Attacks
- Evaluation Bench
- Physical Effects
- Conclusion and Perspectives

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Body Biasing Injection Attacks

- 2 main kinds of hardware attacks:
  - Side Channel Analysis (SCA)
  - Fault Injection Attacks
- Many fault injection methods (Laser, Supply Voltage, etc…) widely studied and with a lot of countermeasures
- **Can we find a new fault injection method?**

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Body Biasing Injection Attacks

- Presented by K.Tobich et al. in 2012
- Apply a high magnitude transient voltage pulse
- On the circuit substrate (request backside access and package opening)
- Positive or negative pulses

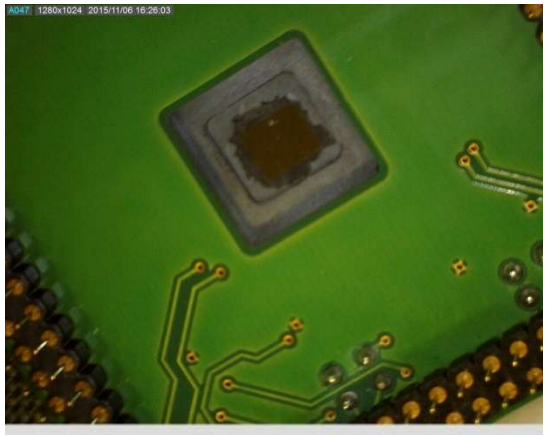

Fig. 1 : A backside opened micro-controller

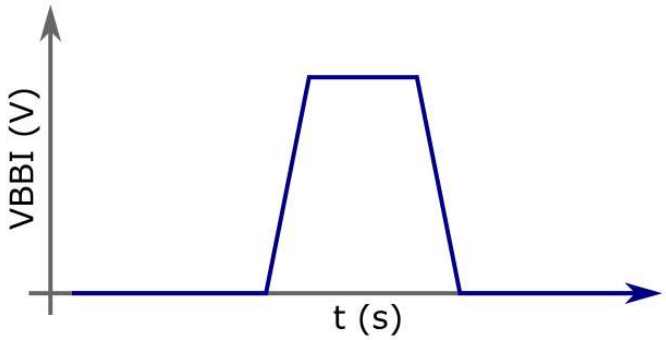

Fig. 2 : A BBI voltage pulse

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Evaluation Bench

- For basic BBI attacks:
  - Backside opened circuit
  - Micro-probe tip
  - Transient voltage pulse generator
  - Oscilloscope
  - Computer
- For sensitivity maps:
  - XYZ stage
  - Weighing scale

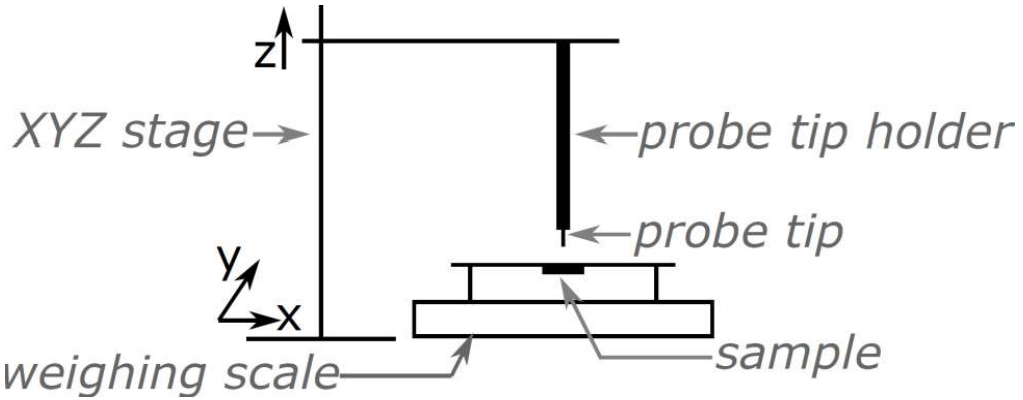

Fig. 3 : Schematic view of the evaluation bench

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Evaluation Bench

- Various attack parameters:
  - Voltage pulse shape
  - Micro-probe tip diameter and contact resistivity
  - Substrate thickness and resistivity
- Main difficulties:
  - Find the appropriate pulse shape
  - Replace the probe properly during sensitivity mappings

Fig. 4 : Damaged circuit (hole in silicon)

Fig. 5 : New and damaged probe tip ends

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Physical Effects

- A first order model built by K. Tobich et al.
- Considers couplings between the external environment, the circuit substrate and the internal power supply nodes
- Does not take into account internal CMOS logic couplings

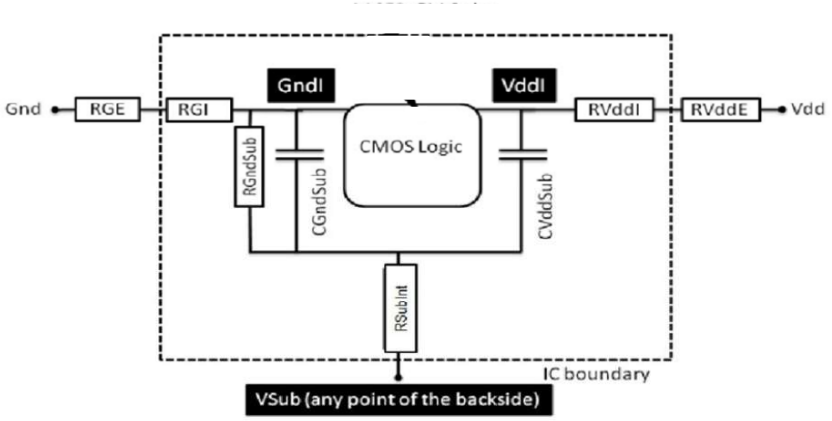

Fig. 6 : 1st order model of an IC power and ground networks

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Physical Effects

- Physical model based on RC couplings between VddI and GndI
- Plus a diode between PMOS and Psub
- Diode activation only for positive pulses (FBBI)

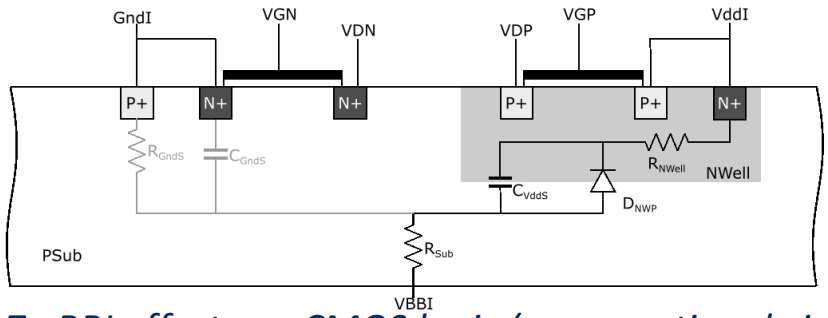

Fig. 7 : BBI effects on CMOS logic (cross sectional view)

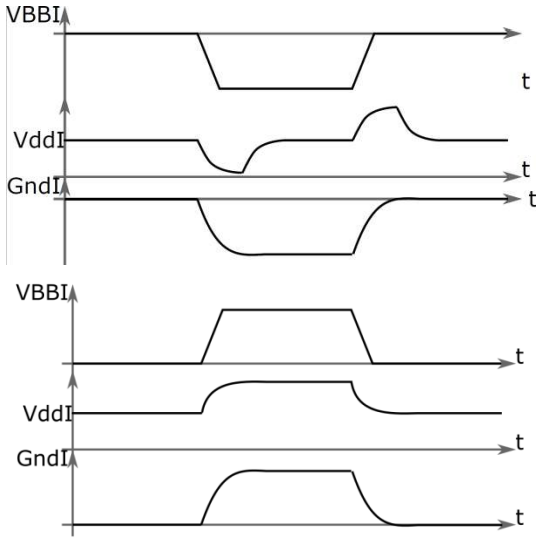

Fig. 8 : RBBI and FBBI effects on VddI and GndI nodes

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Preliminary Results

VBBI trig

VddI

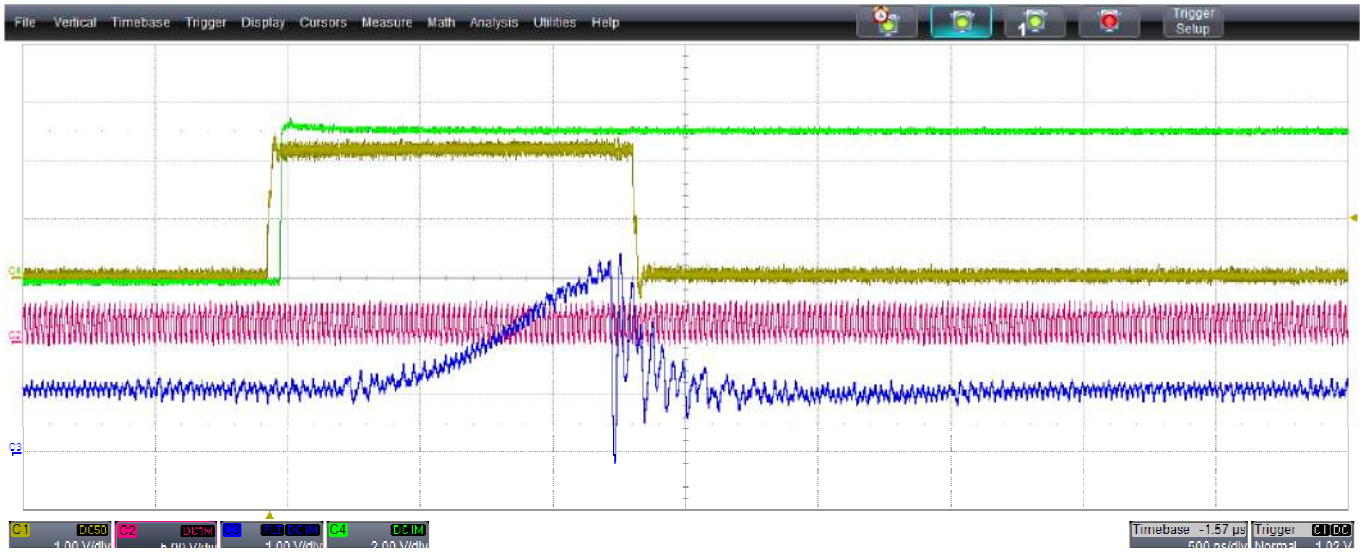

Fig. 9 : Validation of the physical model

- Response shape ok
- A BBI pulse of +60V during 8µs leads to a +2.3V, 1µs pulse on VddI (here on a CMOS 90nm microcontroller)
- Depends on the RC coupling values

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Preliminary Results

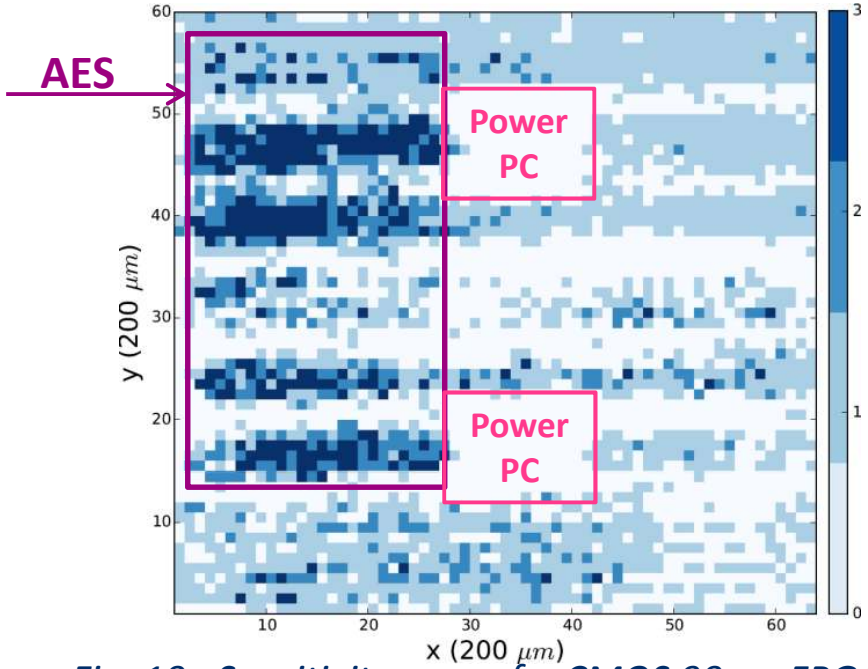

Fig. 10 : Sensitivity map of a CMOS 90nm FPGA

- 60*64 points map (X and Y spaces =200µm)
- -160V, 200ns BBI pulses
- Number of faulty cipher texts for each position and for 3 AES computations

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Conclusion and Perspectives

- An accurate and low cost evaluation bench has been presented
- The physical effects of BBI attacks on CMOS logic has been analyzed
- The sensitivity map provided shows the local effect of BBI attacks
- Further work will include:
  - Analysis of the fault propagation mechanism and fault model investigation (e.g. timing violations, etc.)
  - Attack parameters influence

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